EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S 1	381	"29"/\$.ccls. and (chang-r\$.xa. or chang-r\$.xp.)	USPAT	OR	OFF	2006/04/26 10:14
S2	17	("4230553" "4277321" "4762728" "5363550" "5484494" "5593511" "5599739" "5656542" "5663102" "6025243").PN. OR ("6260266"). URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2006/04/26 10:20
S3	3705	dual adj damascene	USPAT	OR	ON	2006/04/26 10:21
S4	2860	(dual adj damascene) and copper and dielectric	USPAT	OR	ON	2006/04/26 10:28
S5	2365	(dual adj damascene) and copper and dielectric and barrier	USPAT	OR	ON	2006/04/26 13:31
S6	38	("4970574" "5173442" "5404046" "5451804" "5471093" "5550405" "5616959" "5625232" "5629557" "5661344").PN. OR ("5717251"). URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2006/04/26 10:40
S7	1485	(dual adj damascene) and copper and dielectric and ((remov\$ or etch\$) with barrier)	USPAT	OR	ON	2006/04/26 10:47
S8	123	("4574095" "4789648" "4894260" "4985750" "5151168" "5183795" "5192581" "5240497" "5580668").PN. OR ("5824599").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2006/04/26 12:49
S9	2156	(dual adj damascene) and copper and dielectric and (tinsi or ta or tan or tasin or ti or tin or w wn or wsin or wcn or ru)	USPAT	OR	ON	2006/04/27 08:31
S10	17	("3607384" "4169032" "4364099" "4491509" "4760369" "4782380" "4999096" "5910880" "5933753" "5972178" "5972179" "5985762" "5989999" "6002174" "6007684" "6013576" "6028003").PN. OR ("7026238").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2006/04/26 13:40
S11	51	(dual adj damascene) and copper and dielectric and (plasma with silane with ((chemical adj vapr adj deposition) or cvd))	USPAT	OR	ON	2006/04/27 08:52
S12	51	(dual adj damascene) and copper and dielectric and (tan with ((atomic adj layer adj deposition) or ald))	USPAT	OR	ON	2006/04/27 08:39

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S13	20	(dual adj damascene) and copper and dielectric and (etching same barrier same ((physical adj vapr adj deposition) or pvd) same chamber)	USPAT	OR	ON	2006/04/27 09:38
S14	21	(dual adj damascene) and (etching same barrier same ((physical adj vapr adj deposition) or pvd) same chamber)	USPAT	OR	ON	2006/04/27 09:49
S15	0	(dual adj damascene) and (etching same flash same barrier same ((physical adj vapr adj deposition) or pvd) same chamber)	USPAT	OR	ON	2006/04/27 09:55
S16	433	(dual adj damascene) and (barrier same resistivity)	USPAT	OR	ON	2006/04/27 09:55